

Fundumental of Electronic I Msc: Munther Naif Thiyab

Fundumantal of Electronic II

Second Class

Chapter 6 : Field Effect Transistors Lec06_p1 Munther N. Thiyab

2019-2020



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Differences:

- FETs are voltage controlled devices. BJTs are current controlled devices.
- FETs have a higher input impedance. BJTs have higher gains.
- FETs are less sensitive to temperature variations and are more easily integrated on ICs.



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FET Types

•JFET: Junction FET

•MOSFET: Metal–Oxide–Semiconductor FET

D-MOSFET: Depletion MOSFET**E-MOSFET:** Enhancement MOSFET



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JFET Operating Characteristics: $V_{GS} = 0 V$, V_{DS} some positive value

When $V_{GS} = 0$ and V_{DS} is increased from 0 to a more positive voltage:

- The depletion region between pgate and n-channel increases.
- Increasing the depletion region, decreases the size of the nchannel which increases the resistance of the n-channel.
- Even though the n-channel resistance is increasing, the current (I_D) from source to drain through the n-channel is increasing. This is because V_{DS} is increasing.





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JFET Operating Characteristics: $V_{GS} = 0 V$, V_{DS} some positive value ŧI_D Saturation level I_{DSS} $V_{GS} = 0 \text{ V}$ Increasing resistance due to narrowing channel *n*-channel resistance V_P 0 V_{DS} I_D versus V_{DS} for $V_{GS} = 0$ V.

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JFET Operating Characteristics: Pinch Off

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If $V_{GS} = 0$ and V_{DS} is further increased to a more positive voltage, then the depletion zone gets so large that it pinches off the n-channel.

As V_{DS} is increased beyond $|V_P|$, the level of I_D remains the same $(I_D = I_{DSS})$.



I_{DSS} is the maximum drain current for a JFET and is defined by the conditions $V_{GS}=0$ and $V_{DS} > |V_P|$.



 $I_G = 0 \text{ A}$

 $V_{GS} = -1$ V

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 $V_{DS} > 0 V$

JFET Operating Characteristics , V_{GS}<0

- •As V_{GS} becomes more negative, the depletion region increases.
- •The more negative V_{GS} , the resulting level for I_D is reduced.
- •Eventually, when $V_{GS}=V_P$ (-ve) [$V_P=V_{GS(off)}$], I_D is 0 mA. (the device is "*turned off*".

•The level of V_{GS} that results in $I_D=0$ mA is defined by $V_{GS}=V_{P}$, with V_P being a negative voltage for n-channel devices and a positive voltage for p-channel JFETs.

Application of a negative voltage to the gate of a JFET.

 $D \downarrow I_D$



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JFET Operating Characteristics



n-Channel JFET characteristics with $I_{DSS} = 8$ mA and $V_P = -4$ V.

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JFET Operating Characteristics: Voltage-Controlled Resistor

•The region to the left of the pinch-off point is called the ohmic region.

•The JFET can be used as a variable resistor, where V_{GS} controls the drain-source resistance (r_d). As V_{GS} becomes more negative, the resistance (r_d) increases.

$$\mathbf{r_d} = \frac{\mathbf{r_o}}{\left(1 - \frac{\mathbf{V_{GS}}}{\mathbf{V_P}}\right)^2}$$



where r_o is the resistance with $V_{GS}=0$ and r_d is the resistance at a particular level of V_{GS} .



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p-Channel JFETS

The *p*-channel JFET behaves the same as the *n*-channel JFET, except the voltage polarities and current directions are reversed.





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Also note that at high levels of V_{DS} the JFET reaches a breakdown situation: I_D increases uncontrollably if $V_{DS} > V_{DSmax}$.

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